PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT:

MICHAEL BENJE-1 (PCT)

PCT NO.:

PCT/EP99/07649

FILED:

OCTOBER 12, 1999

FOR:

METHOD OF PRODUCING ETHYLENE (DI)CHLORIDE (EDC)

INFORMATION DISCLOSURE STATEMENT

BOX PCT

Assistant Commissioner of Patents Washington, D.C. 20231

Sir:

Applicant is enclosing Form PTO-1449 disclosing the references cited in the International Search Report, copy enclosed. DE 19 05 517, DE 25 40 257 (as amended in the preliminary amendment) and DE 40 39 960 are discussed in the specification on page 1, last paragraph. EP 0 471 987 is also discussed in the specification on page 2, first complete paragraph. DE 24 27 045 is also discussed in the specification on page 3, last paragraph. Since it is believed that copies of the references cited in the search report were submitted by the International Office, no copies of those references are enclosed. Since the instant Information Disclosure Statement is being filed concurrently with the application, no official fee is required in connection with the same. However, if a fee should be required for this IDS, the Commissioner of Patents and Trademarks is hereby authorized to charge any required fee, or to credit any overpayment to Deposit Account No. 03-2468. It is respectfully requested that the foregoing Information Disclosure Statement (IDS) be incorporated into the official file of the concurrentlyfiled patent application.

Respectfully submitted,

MICHAEL BENJE

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Enclosures:

Form PTO-1449, copy of International Search Report

and eleven (11) references

EXPRESS MAIL NO. EL 871 447 544 US Date of Deposit: September 12, 2001

I hereby certify that this paper or fee is being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10, on the date indicated above, and is addressed to the Assistant

Commissioner for Patents, Washington, D.C.